

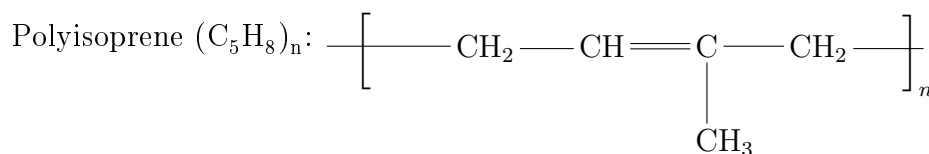
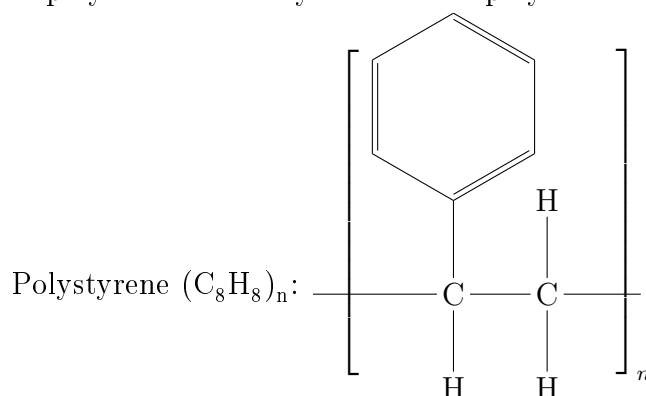
# Chapter 1

## Experimental method

### 1.1 Polymers

Polymers are long chains of molecular units called mers, linked together by covalent bonds. Polymers are both found in biological system and synthesised by chemists. Polymers are described by its properties such as its chemistry, stereochemistry, architecture and what phase it is in.

A polymers chemistry is what the polymer is built of.



With different structures, the polymers display different properties. The different properties of the polymer is also dependant on how the repeating molecular units are bonded together, this is called the polymers stereochemistry. This will not be taken into account during the modelling of the thin films. The polymers architecture describes the general structure of the polymer. The polymers can be linear, branched or cross-linked. Linear polymers are long chains of monomers with bonds that are rigid to a certain degree, and cannot rotate freely, and are normally strong structures. Branched polymers are long chains with side chains attached to the main chain.

These side chains can be comprised of monomers and reactive groups. Branched polymers are normally more softer and less crystalline than linear polymers. Cross-linked polymers are two or more side chains joined together forming a loose two dimensional network. Cross-linked polymers are more rigid and burn rather than melt when heated. The architecture of a polymer can also be expressed with the degree of polymerisation,  $N$ , which characterises the average number of mers units in the chain. It is defined as:

$$N_n = \frac{\bar{M}_n}{\bar{m}}, \quad (1.1)$$

where  $\bar{M}_n$  is the number average molecular weight and  $\bar{m}$  is the mer molecular weight. The average molecular weight is defined as:

$$\bar{M}_n = \sum x_i M_i, \quad (1.2)$$

where  $x_i$  is the fraction of the number of chains with a corresponding size range  $i$  and  $M_i$  is mean molecular weight in the size range  $i$ . There is a dispersion of different polymer sizes in a solution, this dispersion is called the polydispersion index of the polymer and is expressed as:

$$PDI = \frac{\bar{M}_w}{\bar{M}_n}, \quad (1.3)$$

where  $\bar{M}_w$  is the weight average molecular weight and  $\bar{M}_n$  is the number average molecular weight.

In this thesis i will be working with homo-polymers and block-co-polymers. Homo-polymers are long chains of the same repeating monomer, where block-co-polymers are two homo-polymers linearly bonded.

The polymers can also be in a physical state at a given temperature. The chemistry and architecture defines at what temperature the polymer undergoes a phase transition. A polymer can melt and transition into a liquid, which is often very viscous with viscoelastic properties. A polymer has trouble crystallising, polymers are most often in a glassy phase which can be described as amorphous since it looks both like a liquid and a solid. A polymer can crystallise but the crystallisation is not complete because of the polymers architecture. This is called a semi-crystalline state where the polymer has regions behaving liquid like and glass like. And lastly a polymer can be in a liquid crystalline state which involves rigid polymers forming layers.

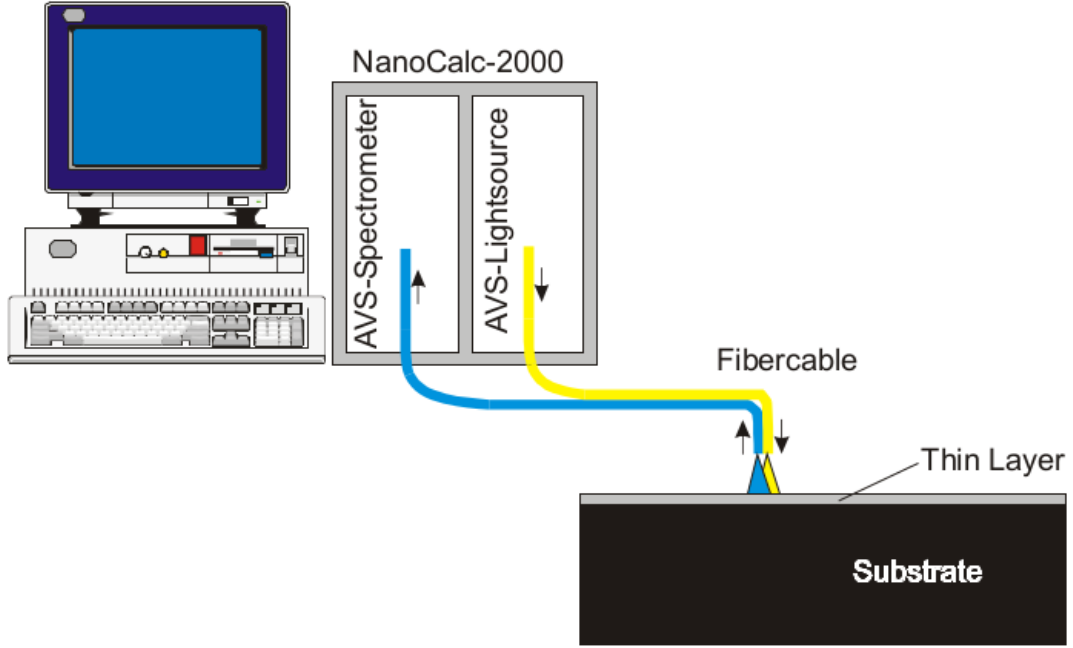


Figure 1.1: This figure describes the NanoCalc set-up and has been taken from [? ]. Light from a light source travels down the optical fiber illuminating the sample. The reflected light is collected by the optical fiber and analysed in the spectrometer. The spectrometer is connected to the computer by USB and the data is stored, modelled and manipulated through the NanoCalc software.

## 1.2 The Experimental Setup

The experimental setup is comprised of a NanoCalc XR and a Halogen light source(HL-2000-FHSA) which can produce wavelengths of 360 nm to 2400 nm. When the samples are being measured they are either placed on the ocean optics single point stage(ADD PICTURE) or in the test chamber(ADD PICTURE) made by the RUC workshop/machinists for x-ray scattering experiments. The NanoCalc is comprised of a spectrometer and an internal light source as seen in the figure 1.1, which can produce wavelengths of 250 nm to 1050 nm and measure thicknesses of 10 nm to 100  $\mu\text{m}$ . The NanoCalc XR is connected to a computer where the NanoCalc software is installed and operated. For the experiments the halogen light source is used since it has a larger output power then the internal light source of the NanoCalc XR. The larger intensity output is need when performing experiments in the test chamber. To reiterate, white light is produced in the light source(HL-2000-FHSA), which travels through optical fiber and strikes that sample. The reflected light travels back through the optical fiber and the intensity across every wavelength of the white light is collected in the spectrometer and is sent to the NanoCalc software.

### 1.3 Reflectance measurements in the NanoCalc spectrometer

The NanoCalc spectrometer measures three light intensities which will be called a measurement onwards. The three measurements are the dark measurement (dark), the reference measurement (ref) and the thin-film measurement (meas). The dark measurement is the amount of light received by the optical fiber from external sources. The reference measurement is the amount of light reflected from a blank silicon wafer and the thin film measurement is the amount of light reflected from the sample. From chapter ??, the reflectance of a sample can be expressed as :

$$R_{sample} = \frac{I_{sample}}{I_{incident}} \quad (1.4)$$

The spectrometer does not measure the intensity of the incident light, therefore the reflectance of the substrate is used to isolate the incident light intensity and inserted into equation 1.4. The reflectance of the substrate is used because it is easily calculated using the Fresnel equations as described in chapter ??.

$$R_{ref} = \frac{I_{ref}}{I_{incident}} \quad (1.5)$$

$$\implies I_{incident} = \frac{I_{ref}}{R_{ref}} \quad (1.6)$$

Inserting equation 1.6 in equation 1.4, the reflectance for the sample is expressed without the incident light intensity as:

$$R_{sample} = \frac{I_{sample}}{I_{ref}} \cdot R_{ref} \quad (1.7)$$

The reflectance of the sample is given as:

$$Reflectance = \frac{Meas - Dark}{Ref - Dark} \cdot R_{sub}, \quad (1.8)$$

This is the same expression given in the NanoCalc spectrometer manual [? ]. Through reproduction of the data and curves given by the NanoCalc spectrometer, i can deduce that the reference measurement has already had the dark measurement subtracted, giving the following reflectance expression:

$$Reflectance = \frac{Meas - Dark}{Ref} \cdot R_{sub}, \quad (1.9)$$

Placing equation 1.9 equal to the reflectance equations using the Fresnel equations from chapters ??, ?? and ??, the NanoCalc spectrometer software can fit a thickness of the sample.

## 1.4 Experimental Protocol

In this section the experimental protocol for both taking measurements without the optics and with the optics are given. The protocol will be formulated in steps.

### 1.4.1 Without Optics

1. Take a continuous reference measurement and adjust the light intensity, such that the reference measurements maximum is 50% of the y-axis.
2. Clear the reference measurement.
3. Take the optic fiber and point it away from anything that can reflect light. Take a dark measurement.
4. Place the optic fiber into ocean optics single point stage. The optic fiber is positioned 4mm above the single point stage.
5. Place a blank silicon wafer under the optic fiber and take a reference measurement.
6. Save the dark and reference measurement.
7. Place a thin film under the optical fiber and take a measurement.

### 1.4.2 With Optics

1. Take a continuous dark measurement with the optic fiber with a dark cloth in the optics where the thin film would lie and adjust the light intensity, such that the dark measurements maximum is at 100% of the y-axis.
2. Clear the dark measurement.
3. Take the optics as a whole and point it away from anything that can reflect. Take a dark measurement.
4. Place a blank silicon wafer into the test chamber and place the optics into the test chamber. Take a reference measurement.
5. Save the dark and reference measurement.
6. Take the optics off the test chamber, remove the blank silicon wafer and place in a thin film sample. Place the optics onto the test chamber. Take a measurement.